Attorney Docket No. 1046.1307

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Paten	t Applica	ation of:	
Tadashi KA	GESAV	VA	
Application	No.: To	be Assigned	Group Art Unit: To be Assigned
Filed: Janu	ıary 26,	2004	Examiner: To be Assigned
For: SEF	RVER D	ATA PROVIDING METHOL	D, MEDIUM AND PROGRAM
		INFORMATION DISC	CLOSURE STATEMENT
Assistant C Washingtor		sioner for Patents 20231	
Sir:			
provided ce the subject	ertain inf U.S. pa	formation which the Examinate tent application. It is reque	re provisions of 37 CFR §1.56, there is hereby er may consider material to the examination of sted that the Examiner make this information of on of the subject application.
1.	Enc	osures accompanying this	Information Disclosure Statement are:
1 1 1 1	a.	application or a PCT Inter English language translati each non-English language Explanations of Relevancy providing a concise explain List of Copending Applica	on (complete or relevant portion(s)) attached to
2.		(Check appropriate satisfied because all non- enclosed "English-languagindicates the degree of re	.98, a concise explanation of what is presently e of each non-English language publication is Items 2a, 2b, 2c and/or 2d) English language publications were cited on the ge version of the search report or action which evance found by the foreign office". (See MPEP nts for an Information Disclosure Statement, Part

A(3): Concise Explanation of Relevance, pp. 600-100 to 600-101, Rev. 1, Feb. 2000.) 2b. set forth in the application. satisfied because an English language translation (complete or relevant 2c. portion(s)) is attached to each non-English language publication. enclosed as Attachment 1(e), hereto. 2d. □ 3. No admission is made that the information cited in this Statement is, or is considered to be, material to patentability nor a representation that a search has been made (other than search report(s) from a counterpart foreign application or a PCT International Search Report, if submitted herewith). 37 CFR §§1.97(g) and (h). Respectfully submitted, STAAS & HALSEY LLP La / 26, 2004 1201 New York Ave., N.W., Suite 700 Washington, D.C. 20005 Registration No. 34,172 Telephone: (202) 434-1500

Facsimile: (202) 434-1501

LIST	OF	ADDITION	ONAL	SUBMITTED
		DOCI	IMEN	ΓS

ATTORNEY DOCKET NO.	APPLICATION NO.
1046.1307	To be Assigned
FIRST NAMED INVENTOR	
Tadashi KAGESAWA	
FILING DATE	GROUP ART UNIT
January 26, 2004	To be Assigned

The following document(s) is/are listed in accordance with the duty of disclosure provisions of 37 CFR § 1.56, so that the Examiner may consider same should he deem any thereof to be material to examination of the subject application. Pursuant to 37 CFR 1.98(a)(2)(iii), a copy of any identified copending application(s) is provided.

It is requested that the Examiner acknowledge his consideration of document(s) below-listed by initialling same in the space provided adjacent each such application and that the Examiner sign and date this form at the bottom thereof to confirm such consideration having been given.

This submission in no way represents an admission that any of the information listed herein constitutes prior art with respect to the subject application and unless and until such prior art status is established, this submission is not a request that the information presented herein be printed on the face of any patent issuing from the subject application in which this information is being filed.

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
	AA						
	AB						

FOREIGN PATENT DOCUMENTS

	DOCUMENT				SUB-	TRANSL	ATION
	NO.	DATE	COUNTRY	CLASS	CLASS	YES	NO
AC							
AD							

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)					LATION NO
	AE	International Search Report		XX	
	AF				
EXAMINE	₹	<u> </u>	DATE CONSIDERED		
*EYAMINE	D. Initi	al if reference considered, whether or no	t citation is in conformance with MPEP 6	00: Draw line thro	uah

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.